

# Mono-Si Texturization Additive MQT-809A

## Increase Efficiency

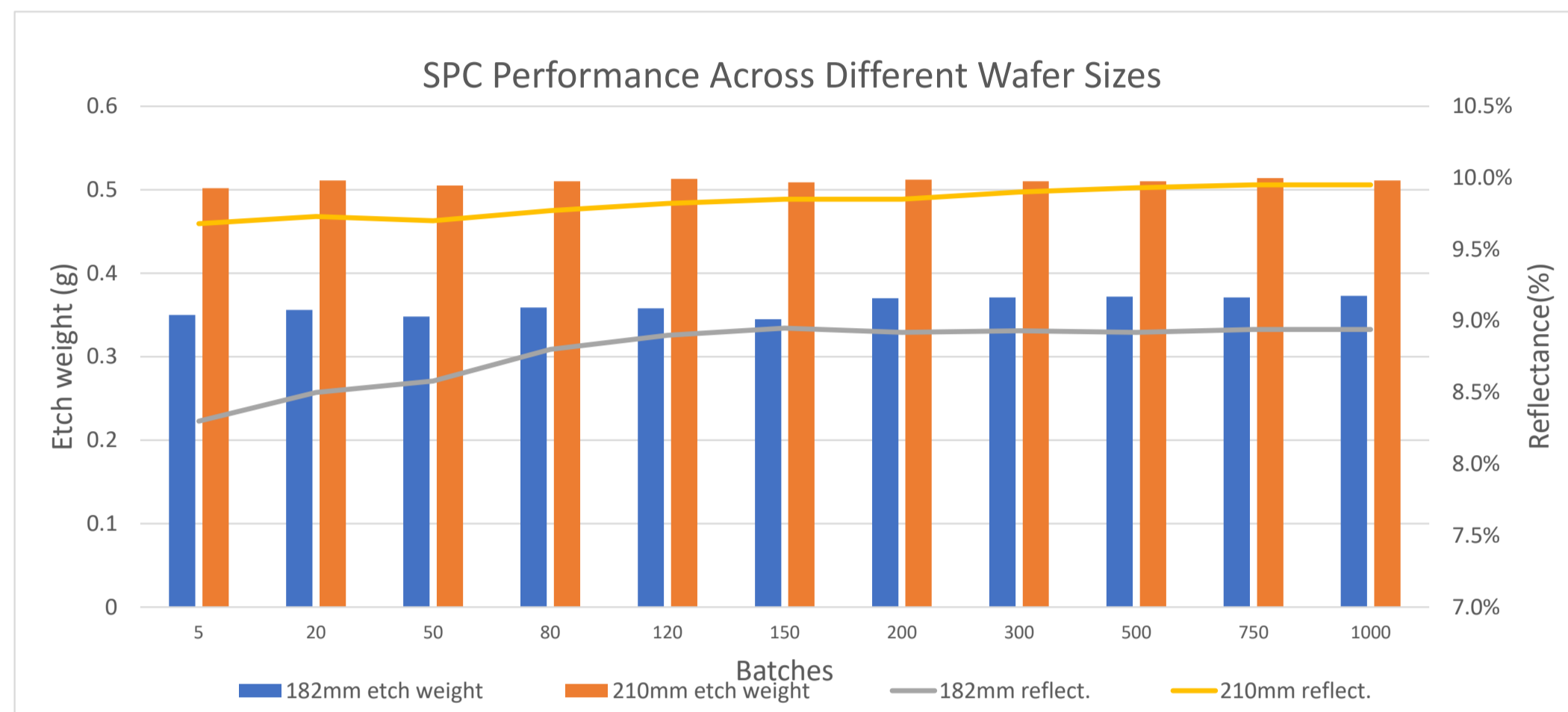
SunFonergy's additive exhibits higher efficiency and stable performance



Item	Eta	Uoc	Isc	FF	IRev2	Rs	Rsh
Baseline	23.212	0.6892	11.462	80.55	0.08	2.20	597.0
SunFonergy	23.254	0.6899	11.473	80.54	0.07	2.22	560.4

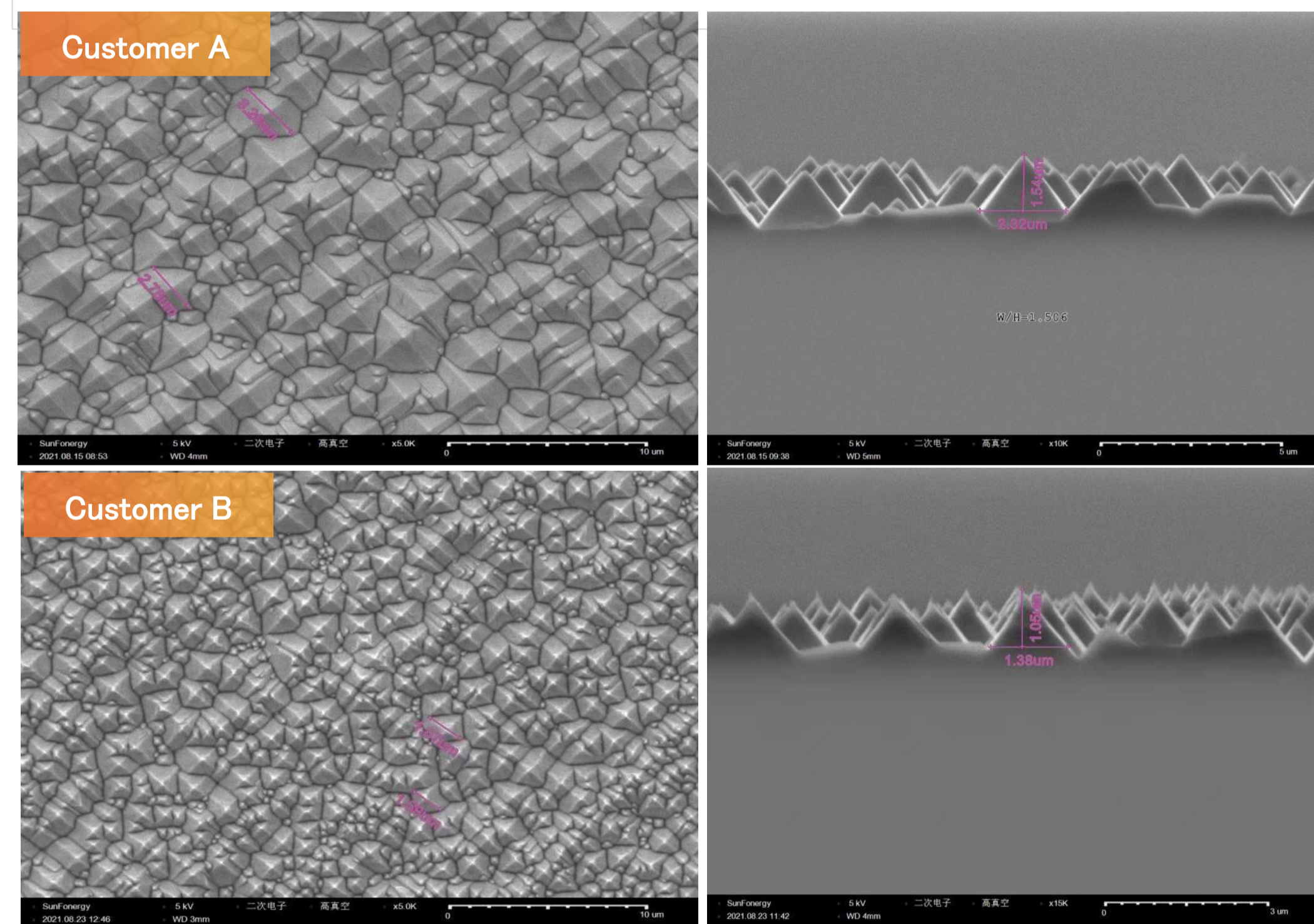
## Low Reflectance

Low reflectance throughout bath lifetime with little variance



## Better Morphology

Lower W/H ratio, with uniform morphology and wide window of pyramid size optimization



## Cost Effective

SunFonergy's additive has a lower chemical consumption than that of competitors



Item	Initial Dosing (L)			Dosing (L / batch)		
	NaOH	DI	Additive	NaOH	DI	Additive
Baseline	3.8	282	1.6	0.41	18	0.105
SunFonergy	3.8	282	1.4	0.40	18	0.105



### Increase Efficiency:

Low reflectance, uniform morphology, stable performance, and high efficiency



### Low Reflectance:

Stable low reflectance throughout lifetime



### Uniform Morphology:

Denser morphology, wide window of pyramid size optimization



### Cost Effective:

Lower chemical consumption